

In the Claims:

1. (Currently Amended) A plated substrate adapted for hard disk medium comprising
a Si single crystal substrate;
an amorphous layer on the substrate, the amorphous layer having thickness of 2 to 200nm and containing Si and one or more metals selected from a group consisting of Ni, Cu and Ag; and
a ~~multicrystal~~ multicrystal layer on the amorphous layer, the multicrystal layer having thickness of 5 to 1000nm and containing Si and one or more metals selected from a group consisting of Ni, Cu and Ag.
2. – 5. (Cancelled)